

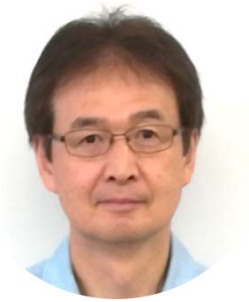
STS Advanced Lithography Session

GETOGETHER

4PM – 5PM **Wed** Dec-11. | Conference Room 102



Hisanobu Azuma
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GETOGETHER is Open to Everyone!

Please stay for the get-together, the exceptional networking opportunities to deepen and extend your business and partnership with the speakers, attendees, and the exhibitors after the session.

For who would join only this event, please come to the room around 4PM.

*Please note that a visitor badge is required to enter this event.

<Seminar Information>

Wed, Dec-11.

2:00PM STS Advanced Lithography Session

- Latest Development of Lithography and Related Technology -

SPEAKERS; Kenji Morisaki (ASML Japan), Yukio Takabayashi (CANON),
Hironobu Taoka (Nihon Synopsys), Toru Fujimori (FUJIFILM)

CALL FOR PRESENTERS OF SPEED NETWORKING *First 5 companies

Speed Networking will allow companies that are interested to present themselves in front of all attendees for 5 minutes and share their views, needs, expectations. If you are willing to take this opportunity and introduce your company, we recommend you to contact us as soon as possible, the places are limited.